

15824 U.S. PTO
10/07/02

NOV 18 2003

U.S. UTILITY Patent Application

PATENT NUMBER and
6650392 DATE

APPL NUM	FILING DATE	CLASS	SUBCLASS	GAU	EXAMINER
10073119	02/12/2002	396	35	2851	H. Nguyen

APPLICANTS: Baselmans Johannes; Moers Marco; Van Der Laan Hans; Willekers Robert; De Boei Wilhelmus; Ven De Kerckhof Marcus;

**CONTINUING DATA VERIFIED:

** FOREIGN APPLICATIONS VERIFIED:
EUROPEAN PATENT OFFICE (EPO) 01301283.6 02/13/2001

PG-PUB	DO NOT PUBLISH	<input type="checkbox"/>	RESCIND	<input type="checkbox"/>
Foreign priority claimed		<input checked="" type="checkbox"/> yes <input type="checkbox"/> no	ATTORNEY DOCKET NO	
35 USC 119 conditions met		<input checked="" type="checkbox"/> yes <input type="checkbox"/> no	P 290667 P-0234.010	
Verified and Acknowledged Examiners Initials		HW		
TITLE : Lithographic projection apparatus, a grating module, a sensor module, a method of measuring wave front aberrations				

U.S. DEPT. OF COMM. / PAT. & TM. PTO-436L (Rev. 12-94)

ISSUE FEE IN FILE

10-5-03 Formal Drawings (2 sheets) set 1 6/12/02

NOTICE OF ALLOWANCE MAILED		CLAIMS ALLOWED	
6/18/03		Total Claims	Print Claim for
ISSUE FEE		15	0.67
Amount Due	Date Paid	DRAWING	
1600	09/16/03	Sheets Drawn	Fig. Drawn
		7	13
TERMINAL DISCLAIMER		Print Fig.	2
		Application Examiner 6/18/03	
		PREPARED FOR ISSUE	
WARNING: The information disclosed herein may be restricted. Unauthorized disclosure may be prohibited by the United States Code Title 35, Sections 122, 181, and 368. Possession outside the U.S. Patent & Trademark Office is restricted to authorized employees and contractors only.			

FILED WITH

DISK (CRF)

CD-ROM

(Attached in pocket on right inside flap)

BEST AVAILABLE COPY